



B & F W

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Batch/Confirmation No.: 9665

Masaru MITSUI et al.

Allowed: November 17, 2004

Group Art Unit: 1752

Application No.: 09/509,472

Examiner: A. Walke

Filed: April 21, 2000

Docket No.: 105875

For: PHOTOMASK BLANK, PHOTOMASK, METHODS OF MANUFACTURING
THE SAME AND METHOD OF FORMING MICROPATTERN

LETTER TO THE OFFICIAL DRAFTSPERSON

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Please substitute the attached nine (9) sheets of formal drawings depicting Figures
1-11 for the corresponding drawings filed with the application. Figure 9 in the attached
drawings has been corrected in accordance with the proposed correction submitted on March
30, 2000 (approved by the Examiner on August 22, 2001).

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Christopher W. Brown
Registration No. 38,025

JAO:CWB/cb

Date: January 6, 2005

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

DEPOSIT ACCOUNT USE
AUTHORIZATION
Please grant any extension
necessary for entry;
Charge any fee due to our
Deposit Account No. 15-0461